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Docket No.: IPA-000

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Inventor(s): Akira NAKASHIMA et al.

U.S. Patent Application No.: Not yet assigned

Filed: herewith

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Confirmation No.

Group Art Unit: Not yet assigned

For: METHOD OF FORMING AMORPHOUS SILICA-BASED COATING FILM WITH
LOW DIELECTRIC CONSTANT AND THUS OBTAINED SILICA-BASED
COATING FILM

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450


Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached form PTO-1449. It is respectfully requested that the documents be expressly considered during the prosecution of this application, and that the documents be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is being filed within three months of the U.S. filing date OR before the mailing date of a first Office Action on the merits. No certification or fee is required.

Respectfully submitted,

HAUPTMAN KANESAKA BERNER Patent Agents, LLP


Manabu Kanesaka
Registration No. 31,467

1700 Diagonal Road, Suite 300
Alexandria, Virginia 22314
(703) 519-9785
Facsimile: (703) 519-7769
Date: January 18, 2005
MAN/eb

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INFORMATION DISCLOSURE CITATION IN AN APPLICATION (PTO-1449)				ATTY. DOC. NO. IPA-006		U.S. APPLICATION NO. Not yet assigned	
				APPLICANT Akira NAKASHIMA et al.			
				FILING DATE herewith		GROUP	
U.S. PATENT DOCUMENTS							
EXAMINER'S INITIALS	PATENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE	
	2001/0051446 A1	12/13/2001	INOUE et al				
	2002/0060364 A1	05/23/2002	YAN et al				
	6 451 436 B1	09/17/2002	KOMATSU et al				
	6 639 015 B1	10/28/2003	NAKASHIMA et al				
FOREIGN PATENT DOCUMENTS							
EXAMINER'S INITIALS	PATENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						Yes	No
OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)							
	Patent Abstract of Japan; Publication No.: 2003-249495; Publication Date: 09/05/2003; Applicant: ASAHI KASEI CORP						
	Patent Abstract of Japan; Publication No.: 2003-027001; Publication Date: 01/29/2003; Applicant: JSR CORP						
	Patent Abstract of Japan; Publication No.: 2002-069375; Publication Date: 03/08/2002; Applicant: JSR CORP						
	Patent Abstract of Japan; Publication No.: 2002-020689; Publication Date: 01/23/2002; Applicant: JSR CORP						
	Patent Abstract of Japan; Publication No.: 2002-030249; Publication Date: 01/31/2002; Applicant: CATALYST & CHEM IND CO LTD						
	Patent Abstract of Japan; Publication No.: 2000-349083; Publication Date: 12/15/2000; Applicant: NIPPON ASM KK						
	Patent Abstract of Japan; Publication No.: 09-315812; Publication Date: 12/09/1997; Applicant: CATALYST & CHEM IND CO LTD						
EXAMINER				DATE CONSIDERED			

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.

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